

Pulse Height Analysis of 3D pCVD Diamond Detectors

RD42 Meeting

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8th May 2019

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- 3 Pulse Height Calibration
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Section 1

Introduction

Diamond as Detector Material

- innermost tracking layers \rightarrow highest radiation damage \mathcal{O} (GHz/cm²)
- \rightarrow **R&D towards more radiation tolerant detector designs and/or materials**

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Work at ETH:

- investigate signals and radiation tolerance in various detector designs:
 - ▶ Pad Detectors \rightarrow whole diamond as single cell readout
 - ▶ Pixel Detectors \rightarrow diamond sensor on pixel readout chip
 - ▶ 3D Pixel Detectors \rightarrow 3D diamond detector on pixel readout chip

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 - ▶ Pad Detectors
 - ▶ Pixel Detectors
 - ▶ **3D Pixel Detectors** \rightarrow this talk

Detectors

	II6-A2	II6-B6
manufacturer	II-VI Inc.	II-VI Inc.
diamond type	poly-crystal	poly-crystal
size	$\sim 4 \text{ mm} \times 4 \text{ mm}$	$\sim 4 \text{ mm} \times 4 \text{ mm}$
thickness	$\sim 500 \mu\text{m}$	$455 \mu\text{m}$
irradiation	none	none
construction	summer 2016	summer 2017
3D drilling	Oxford	Oxford
3D cell size	$150 \mu\text{m} \times 100 \mu\text{m}$	$50 \mu\text{m} \times 50 \mu\text{m}$
columns	20×30 (600)	60×62 (3720)
pixel chip	PSI46digV2.1respin (CMS)	PSI46digV2.1respin (CMS)
pixel pitch	$150 \mu\text{m} \times 100 \mu\text{m}$	$150 \mu\text{m} \times 100 \mu\text{m}$
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Table: 3D Pixel Detector Properties.

- II6-A2 broke in October 2016 (chip malfunctioned) → successful re-bonding
- II6-B6 has long history of breaking ...

Measurements

	Oct 16	May 17	Aug 17	Sep 18	Oct 18	Nov 18
place	PSI	PSI	PSI	CERN	CERN	PSI
II6-A2	✓	✓	✓	✓	✓	✓
II6-B6	✗	✗	✓	✓	✓	✓

Table: 3D Pixel Detector Measurements.

- standard rate and voltage scans
- rise time scans: change of amplifier rise time at fixed flux and voltage
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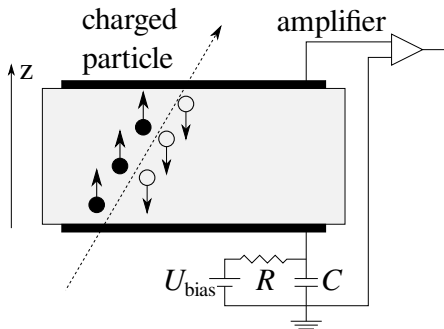
History of II6-B2:

- 06/2017 - sensor processing and detector fabrication
- 08/2017 - first measurement → wrong chip calibration → high threshold (~ 10 ke)
- 04/2018 - several pixels malfunction → re-bump-bonding to new chip
- 06/2018 - sensor detaches while shipping → re-bump-bonding, fixate with silguard
- 11/2018 - efficiency worsens and sensor detaches again

Section 2

3D Pixel Detector

Diamond as Particle Detector



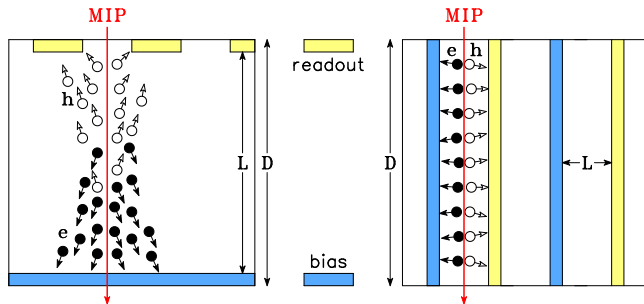
(a) Detector Schematics



(b) 15 cm \varnothing pCVD Diamond Wafer

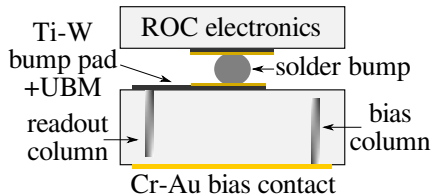
- detectors operated as ionisation chambers
- metallisation on both sides
- poly-crystals produced in large wafers

Working Principle

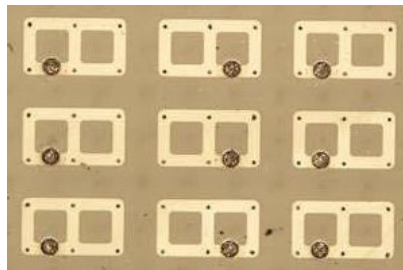


- after large radiation fluence all detectors become trap limited
- bias and readout electrode inside detector material
- same thickness $D \rightarrow$ same amount of induced charge \rightarrow shorter drift distance L
- **increase collected charge in detectors with limited mean drift path (Schubweg)**

Bump Bonding



(a) Bump bond schematics



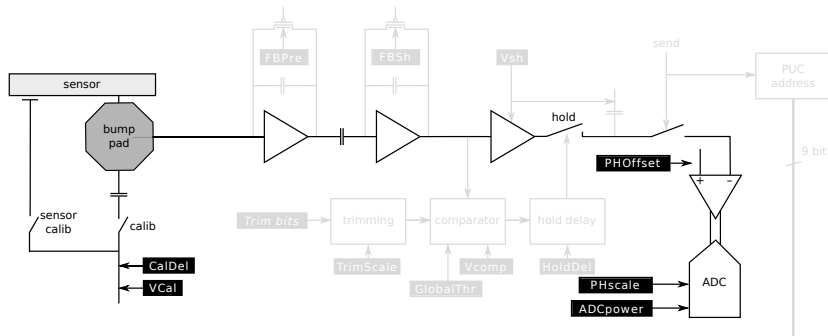
(b) 3×2 bump pads

- electrodes (columns) drilled with femto-second laser
- connection to bias and readout with surface metallisation
- ganging of cells to match pixel pitch of readout-chip (ROC)
- small gap ($\sim 15 \mu\text{m}$) to the surface to avoid a high voltage break-through

Section 3

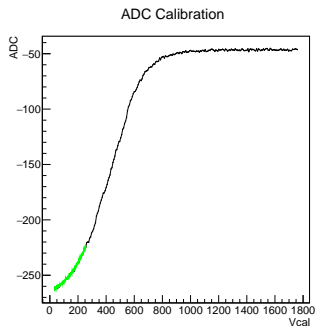
Pulse Height Calibration

Pixel Unit Cell

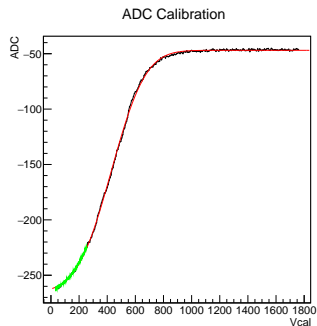


- inject calibration signal ($\sim vcal$) through sensor into same circuit as real signals
- shaping, amplification, threshold check
- set amplification offset
- convert to 8 bit adc value with adjustable scale \rightarrow readout

ADC Calibration



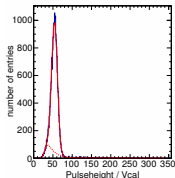
(a) ADC calibration for single pixel.



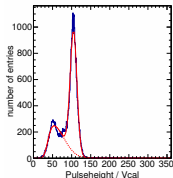
(b) Error function fit.

- measure adc values for calibration pulses with different vcal
- adc follows error function and saturates for high vcal
- fit every pixel and save fit parameters
- adjust adc offset and range with DACs of the chip

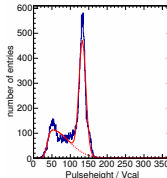
Vcal Calibration



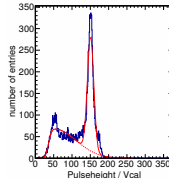
(a) Zn target.



(b) Mo target.



(a) Ag target.



(b) Sn target.

- measure energy spectra of K_{α} lines of four metal targets using ADC-calibration

Vcal Calibration

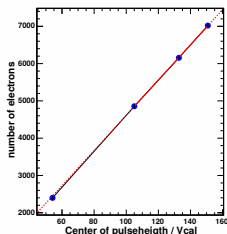


Figure: Vcal Calibration.

- measure energy spectra of K_{α} lines of four metal targets using ADC-calibration
- linear dependence of energy [e] and vcal
- fit K_{α} points with straight line (similar for each chip)
- impossible to do calibration with diamond (energy too low)
 - ▶ use general value from silicon: $e = 47.5 \cdot vcal + 500 e$

Section 4

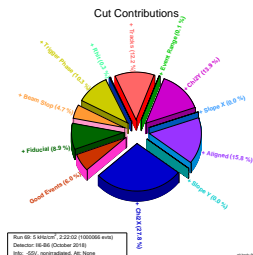
Analysis

Cuts

Cut	Excluded Events
event range	first minute of the run due to various beam conditions
beam interruptions	during rate changes of the beam due to beam interruption
aligned	DUT and Telescope are not aligned (event-wise)
trigger phase	Chip trigger timing is incorrect
tracks	not all telescope planes have exactly one cluster
chi2 (x/y)	badly fit tracks ($>50\%$ quantile)
track slope (x/y)	large angles of the tracks ($>2\text{ deg}$)
rhit	large DUT residual ($>100\text{ mm}$)
pixel mask	noisy pixels
fiducial	not in selected (fiducial) area of the DUT

Table: Analysis cut flow.

- cuts applied in order of the table
- largest contribution usually by chi2, tracks and fiducial cuts



Section 5

Conclusion

Conclusion

- empty
- moreempty
- moremoreempty

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